

# 3-OCTADECYLPYRROLE



95 Horse Block Road, Yaphank NY 11980-9710  
Tel: (877) 447-6266 (Toll-Free in US) or (631) 205-9490 Fax: (631) 205-9493  
Tech Support: (631) 205-9492 tech@nanoprobes.com  
www.nanoprobes.com

## PRODUCT INFORMATION

### 3-OCTADECYLPYRROLE

Product Name: 3-OCTADECYLPYRROLE  
Catalog Number: 3ODP  
Appearance: Pale tan powder  
Revision: 1.3 (March 2000)

#### GENERAL INFORMATION

3-OCTADECYLPYRROLE is a surface-active pyrrole derivative which may be oxidised to form a highly conductive molecular monolayer. It may be mixed with pyrrole and applied to a water surface containing ferric chloride (FeCl<sub>3</sub>). Langmuir-Blodgett techniques may be used to control the film produced.

3-OCTADECYLPYRROLE is supplied pure, as a powder. It should be refrigerated upon receipt, and stored at 2 - 8°C.

#### INSTRUCTIONS FOR USE

**Formation of EM substrate films:**<sup>1</sup> Cast a solution of the pyrrole in ethyl acetate (0.0015 g/mL) onto an air-water interface where the water contains 1 wt % ferric chloride. Free pyrrole as a vapor is added to initiate polymerization (place both the solution and an open container of pyrrole under a bell jar); the films may be controlled by using dental floss to control their spread, or more effectively by using a Langmuir-Blodgett trough for their generation. Drop the grids onto the film, then pick them up, wash as for thin carbon films, and apply the sample as usual.

**General:** Detailed instructions for monolayer formation, oxidation and monolayer manipulation are described by Hong et al.<sup>2</sup> Pure 3-OCTADECYLPYRROLE, or 1 : 300 or 1 : 5000 mixtures with pyrrole, are applied to the surface of a 1 wt % ferric chloride solution, then washed with deionized water and 5 % HCl after oxidation. Highly conducting films may be prepared by the method of Bocchi,<sup>3</sup> using a solution of pure 3-OCTADECYLPYRROLE applied to the surface of a 10 wt % solution of ferric chloride.

#### REFERENCES

1. Simon, M. N.; Lin, B. Y.; Lee, H. S.; Skotheim, T. A., and Wall, J. S.: *Proc. XIIIth Int. Congress for Electr. Micr.*, San Francisco Press, Inc., San Francisco, CA, **1990**; Vol. 1, pp. 290-291.
2. Hong, K., and Rubner, M. F.; *Thin Solid Films*, **1988**, 160, 187; Hong, K.; Rosner, R. B., and Rubner, M. F.; *Chem. Mater.*, **1990**, 2, 82.
3. Bocchi, V., and Gardini, G. P.; *J. Chem. Soc. Chem. Commun.*, **1986**, 148.

Technical Assistance Available.

For a complete list of references citing this product, please visit our world-wide-web site at <http://www.nanoprobes.com/Ref.html>.